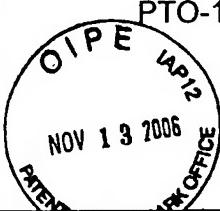


INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)			Atty. Docket #	Serial No.			
PTO-1449 (modified)			2004.834 US	10/594,104			
			Applicant W. DE GRAAFF et al.				
			Filing Date	Art Unit			
U.S. PATENT DOCUMENTS							
Init	Document No.	Issue Date	Name	Class	Subclass	Filing Date	
PD	3,995,633	12-1976	Gougeon	128	260		
PD	3,995,634	12-1976	Drobish	128	260		
PD	4,237,885	12-1980	Wong et al.	128	260		
PD	4,292,965	10-1981	Nash et al.	128	260		
PD	4,596,576	06-1986	De Nijs	604	892		
PD	6,544,546 B1	04-2003	Joseph Groenewegen et al.	424	432		
FOREIGN PATENT DOCUMENTS						Translation	
	Document No.	Publ. Date	Country	Class	Subclass	Yes	No
PD	WO 97/02015 A1	01-1997	PCT International	A61K	9/00		
PD	WO 99/30976 A1	06-1999	PCT International	B65D	33/25		
PD	0 050 867 A1	01-1988	European Patent Office	A61M	31/00		
PD	0 876 815 A1	11-1998	European Patent Office	A61K	9/00		
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
Not published							
International Search Report for Int'l Application No. PCT/EP2005/051189 dated July 28, 2005.							
Written Opinion for International Application No. PCT/EP2005/051189 dated September 26, 2006.							
PD	Van Laarhoven, J.A.H. et al., "In vitro release properties of etronogestrel and ethinyl estradiol from a contraceptive vaginal ring," International Journal of Pharmaceutics 232 (2002) pp. 163-173.						
PD	Sam, A. P., "Controlled release contraceptive devices: a status report," Journal of Controlled Release, Vol. 22, No. 1 (1992) pp. 35-46.						
PP	Zanefeld, L.J.D. et al., "Use of mandelic acid condensation polymer (SAMMA), a new antimicrobial contraceptive agent, for vaginal prophylaxis," Fertility and Sterility, Vol. 78, No. 5 (2002) pp. 1107-1115.						
EXAMINER <i>Paul W. Dutka</i>			DATE CONSIDERED 1/23/08				

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.